



Certificate of Presentation

We hereby certify that the work

Procedure to use diamond layout style and reduce analogue IC area

by

**José Roberto Banin , Salvador Pinillos Gimenez, Rodrigo Alves de Lima Moreto and
G. A. da Silva**

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A handwritten signature in blue ink, which appears to read "Jacobus Swart". The signature is written in a cursive style and is positioned above a horizontal line.

Dr. Jacobus Swart
SEMIMATEC 2019 General Chair